Diffusion Doping of Cobalt in Rod-shape Anatase TiO₂ Nanocrystals Leads to Antiferromagnetism

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Supporting information

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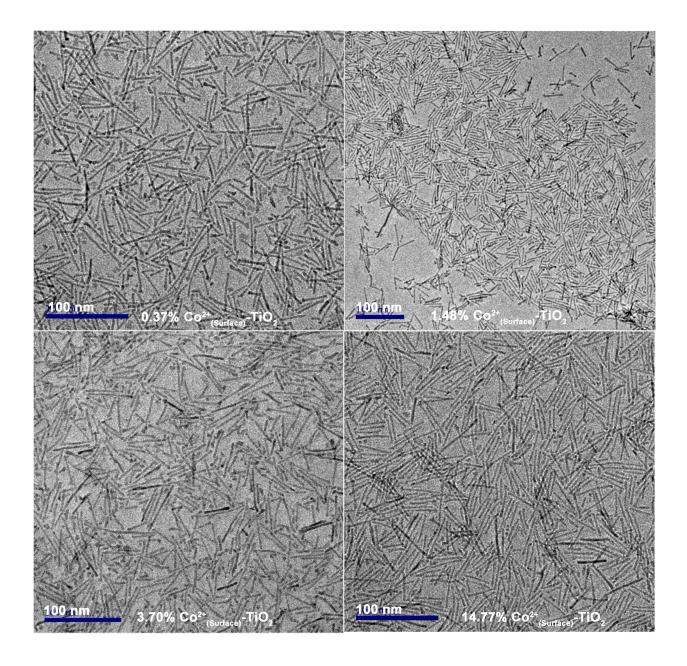


Figure S1. TEM images of $Co^{2+}_{(surface)}$ -TiO₂. Top left: 0.37% $Co^{2+}_{(surface)}$ -TiO₂. Top right: 1.48% $Co^{2+}_{(surface)}$ -TiO₂. Bottom left: 3.70% $Co^{2+}_{(surface)}$ -TiO₂. Bottom right: 14.77% $Co^{2+}_{(surface)}$ -TiO₂. All scale bars are 100 nm.

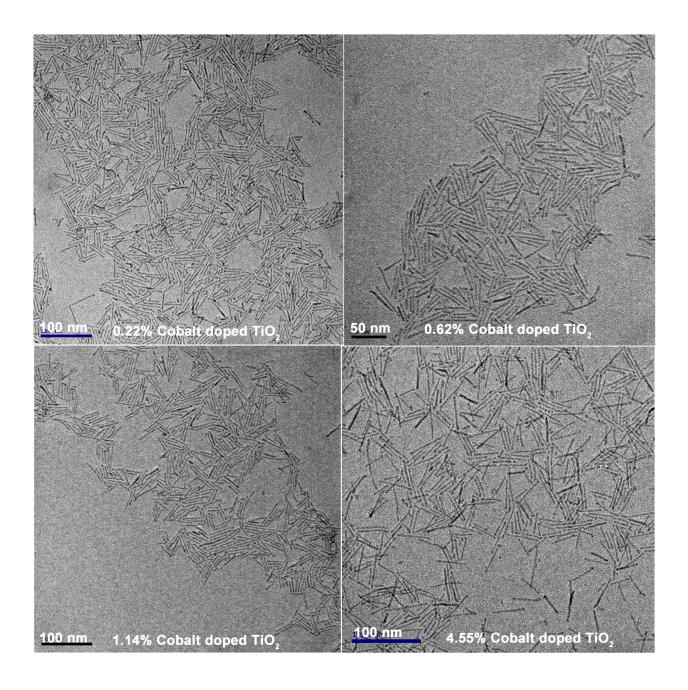


Figure S2. TEM images of $Co^{2+}_{(doped)}$ -TiO₂. Top left: 0.22% $Co_{(doped)}$ -TiO₂, scale bar = 100 nm. Top right: 0.62% $Co_{(doped)}$ -TiO₂, scale bar = 50 nm. Bottom left: 1.14% $Co_{(doped)}$ -TiO₂, scale bar = 100 nm. Bottom right: 4.55% $Co_{(doped)}$ -TiO₂, scale bar = 100 nm.

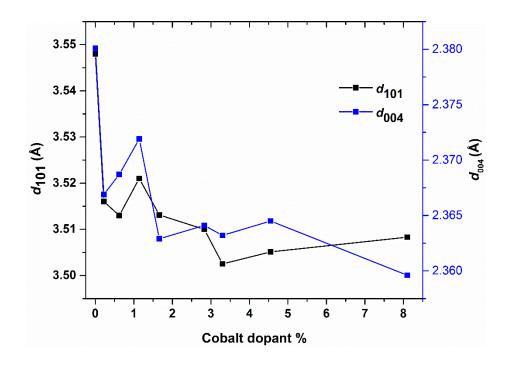


Figure S3. d-spacing of TiO₂ with different cobalt-dopant percentage.

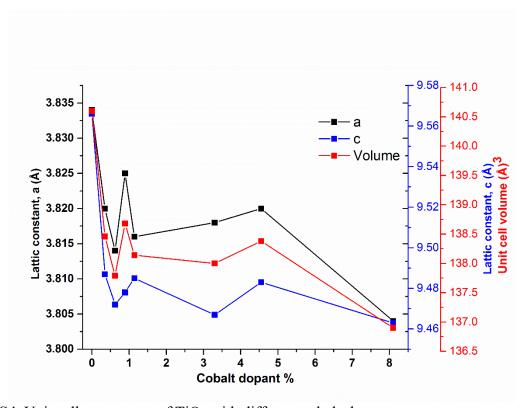


Figure S4. Unit cell parameters of TiO₂ with different cobalt-dopant percentage.

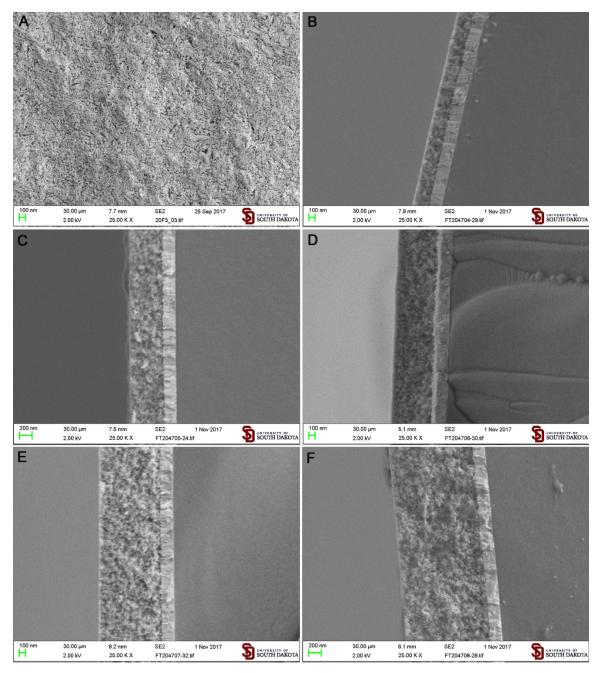


Figure S5. SEM images of prepared thin films with 2.83% cobalt doped TiO₂ nanorods. A) Top view; Cross sectional view of B) 2 layers of film, C) 4 layers of film, D) 6 layers of film, E) 8 layers of film, F) 10 layers of film.

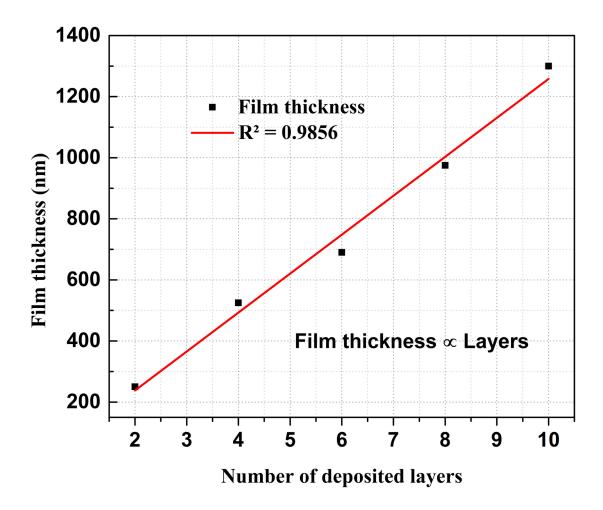


Figure S6. Film thickness versus number of deposition steps.